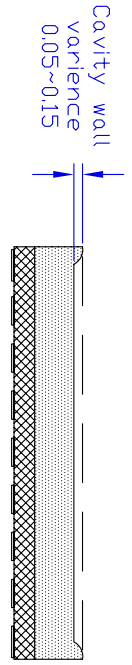
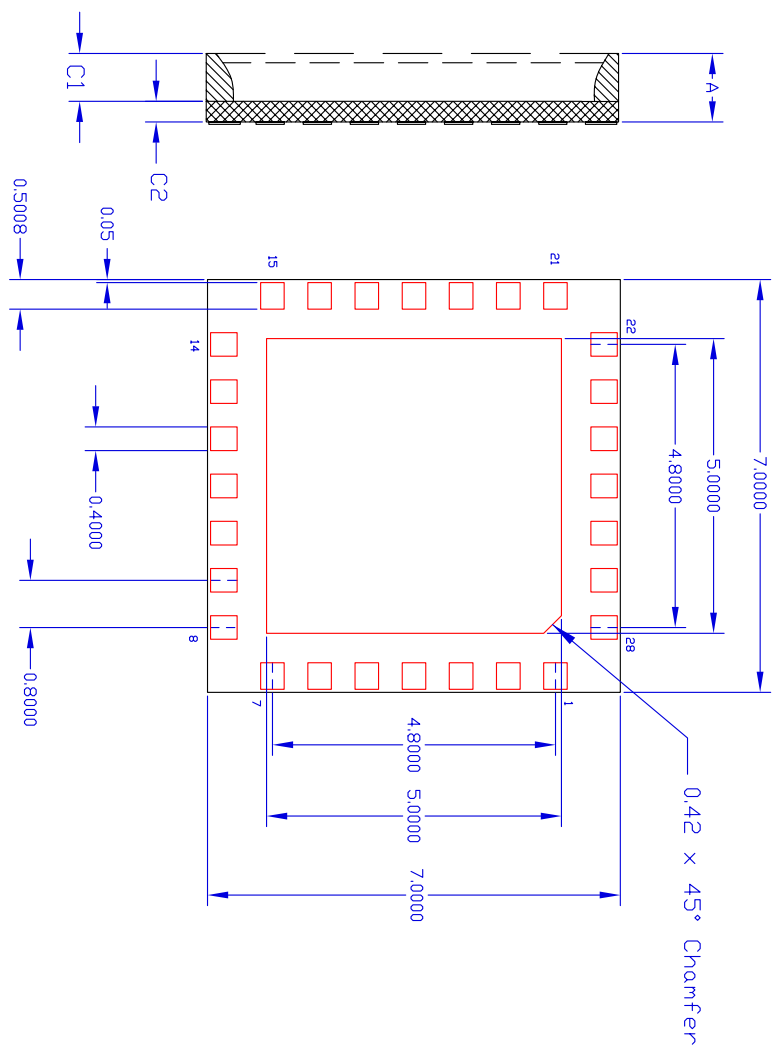
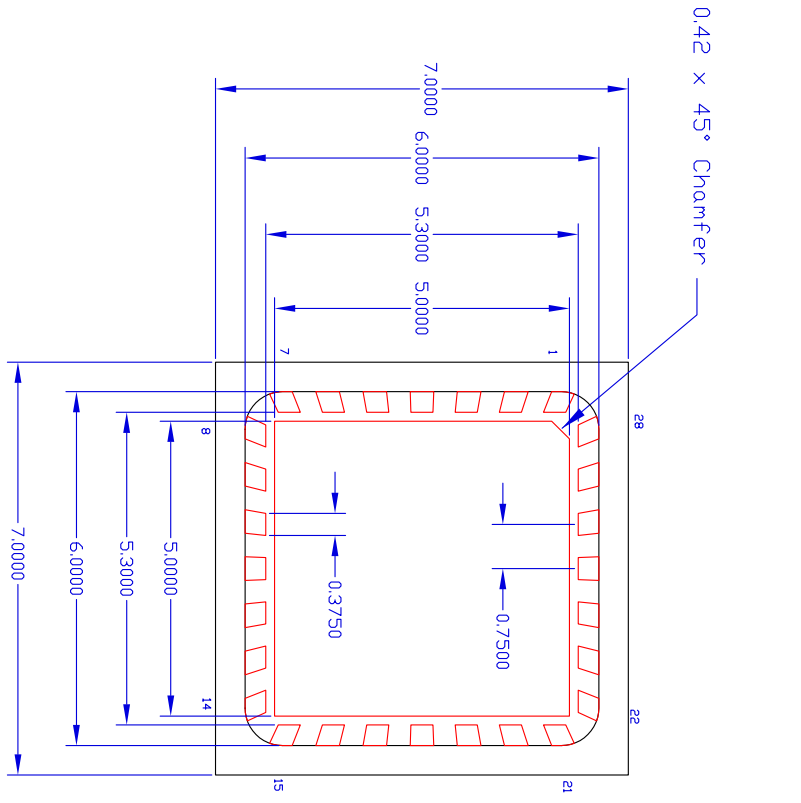


TOP VIEW

SIDE VIEW

BOTTOM VIEW



SIDE VIEW

HEIGHT TABLE			
SERIES	C1	C2	A
A-QFN	0.63	0.27	0.90
A-TQFN	0.38	0.27	0.65
TOL	+/- 0.10	+/- 0.05	+/- 0.15

OTHER SIZES AVAILABLE

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Note:

1. Organic substrate
2. Cavity Dam: Hysol FP4451TD
3. Pads: Cu/Ni/Au
4. Copper Thickness: 12µm~18µm (0.5~0.7mil)
5. Bonding Pad Gold Thickness: 1.3µm (50 micro-inch)
6. PCB Pads Gold Thickness: 0.13µm (5 micro-inch)
7. Nickel Thickness: 38µm (150 micro-inch)
8. All Dimensions Are mm

TOLERANCES UNLESS NOTED:		APPROVALS		DATE	
X.XX	±	DRAWN TA		11/29/08	
X.XXX	±				
X.XXXX	±				
ALL DIMENSIONS ARE IN:		ENG		MFG	
<input type="checkbox"/> INCHES <input type="checkbox"/> MILLIMETERS		QA		SCALE	
THIRD ANGLE PROJECTION:		CUST		SIZE	
		REVISED		DRAWING NO.	
				482810	
				REV	
				A	
				SHEET 1 OF 1	
				DO NOT SCALE DRAWING	



TITLE 28-LEAD 7MM P=0.80MM
A-QFN (AIR) OPEN CAVITY